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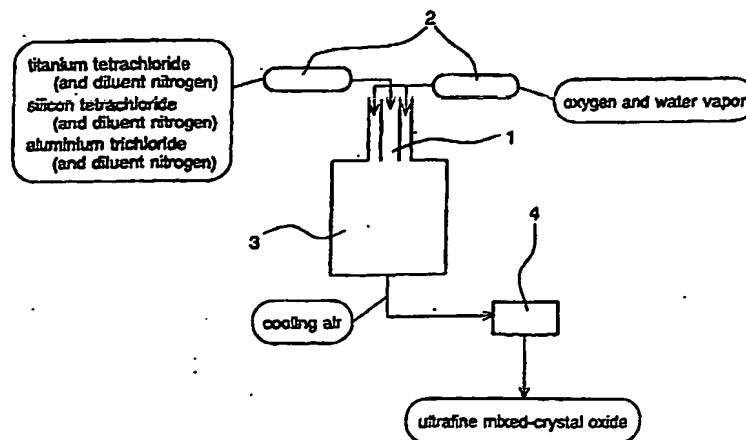
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(54) **ULTRAFINE MIXED-CRYSTAL OXIDE PARTICLES, PROCESS FOR PRODUCING THE SAME, AND USE**

(57) A process for producing an ultrafine mixed-crystal oxide characterized by producing an ultrafine mixed crystal oxide comprising primary particles in a mixed crystal state and having a BET specific surface area of 10 to 200 m²/g, comprising the step of subjecting a halogenated metal to high temperature oxidation with an oxidizing gas to produce a metal oxide by a vapor phase production method, wherein the halogenated

metal is in the form of a mixed gas (a mixed halogenated metal gas) comprising at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum, and the mixed halogenated metal gas and the oxidizing gas are independently preheated to 500°C or more prior to a reaction, a ultrafine mixed crystal oxide obtained by the process, and use of the oxide.

FIG. 1



Description

TECHNICAL FIELD

5 [0001] The present invention relates to an ultrafine mixed-crystal oxide obtained by a vapor phase method, and the production process thereof. More specifically, the present invention relates to an ultrafine mixed-crystal oxide with a mixed-crystal state, prepared from a mixture selectively comprising a plurality of chlorides, bromides, and iodides of titanium, silicon, and aluminum with an arbitrary composition ratio, the production process and the use thereof.

10 BACKGROUND ART

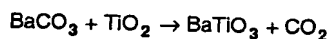
[0002] The fields of industrial application of the ultrafine oxides have been expanding considerably in recent years. For instance, ultrafine titanium oxide is being extensively studied as an ultraviolet-shielding agent, an additive for a silicone rubber, and a photocatalyst. In particular, the application for cosmetics attracts special attention due to the
15 ultraviolet shielding effect of ultrafine titanium oxide, and, in light of the photocatalytic properties of the ultrafine titanium oxide, some attention is also being paid to the application for prevention of fouling, sterilization, and deodorizing. Such applications are supported by the advantages of ultrafine titanium oxide in terms of safety, processability, functional characteristics, and durability. The ultrafine particles have not been exactly defined, but are generally regarded as fine particles with a primary particle diameter of about 0.1 μm or less.

20 [0003] The specific functions of titanium oxide, that is, scattering and absorption of ultraviolet light, are noteworthy. It is more noticeable that ultrafine particles of titanium oxide are favorably provided with the above-mentioned two functions in combination. For instance, ultrafine titanium oxide with a primary particle diameter of about 80 nm can work to effectively scatter ultraviolet light. In addition, it is known that such ultrafine particles of titanium oxide can effectively absorb ultraviolet light with a wavelength of about 400 nm or less and be excited to generate electrons and/
25 or holes in the portion adjacent to the surface of the particle, thereby exhibiting such photocatalytic performance as to carry out the prevention of fouling, sterilization, and deodorizing, as mentioned above.

[0004] However, when titanium oxide having such functions is used for cosmetic applications in practice, there is the possibility that the titanium oxide works improperly unless subjected to a surface treatment (coating). This is because the electrons and holes caused by photo-excitation generate various radicals when allowed to react with oxygen and
30 water in the air, so that they work to decompose organic materials in the air.

[0005] Titanium oxide is also used as a high-performance dielectric material. For example, titanium oxide is subjected to a solid phase reaction with barium carbonate at 1,200°C in accordance with the following reaction formula, thereby providing barium titanate serving as a dielectric material.

35



[0006] In this case, barium carbonate decomposes at around 700°C to generate BaO with high tendency of ionization, which is diffused into TiO_2 particles with covalent bonding characteristics to form a solid solution, thereby producing
40 barium titanate. The particle size of the barium titanate is determined by the crystalline size of the TiO_2 in the course of the reaction. Therefore, the crystallinity and the particle size of the titanium oxide serving as the raw material become significant. To cope with the requirement for a small-size ceramic condenser with a high dielectric constant, there is an increasing demand for ultrafine particles of barium titanate, and consequently, for ultrafine particles of titanium oxide as a raw material.

45 [0007] However, the growth of titanium oxide particles with a particle size of 0.1 μm or less is striking at the above-mentioned reaction temperature of about 700°C, so that there is the problem that such titanium oxide particles cannot contribute to the provision of ultrafine particles of barium titanate. Ultrafine particles of titanium oxide for achieving the above-mentioned object is desired.

50 [0008] As an example of a method for producing fine particles of a composite containing titanium oxide, a production process is known for finely-divided particles of silica - titania composite material, that is, a production process of allowing a mixture of gaseous halogenated silicon and gaseous halogenated titanium to react with oxidizing gas containing an oxygen at 900°C or more (Japanese Laid-Open Patent Application No. 50-115190). According to this method, the mixture of gases serving as the raw material is subjected to a reaction under conditions of a high temperature of 900°C or more without preheating. The resultant composite particles have such a structure that crystalline TiO_2 particles are
55 always deposited on the surface of the composite particles.

[0009] Japanese Patent No. 2503370 (European Patent No. 595078) discloses that a mixed oxide of titanium oxide, aluminum oxide, and silicon oxide can be produced by flame hydrolysis (at a reaction temperature of 1000 to 3000°C) using chlorides as raw materials. The flame hydrolysis produces a mixed oxide of Al_2O_3 and TiO_2 , or a mixed oxide of

SiO₂ and TiO₂. Similarly, Japanese Patent No. 2533067 (European Patent No. 585544) discloses manufacture of a mixed oxide of aluminum oxide and silicon oxide by flame hydrolysis.

[0010] As previously mentioned, the production process for a metal oxide by a vapor phase method, or the production process for a metal oxide or mixed metal oxide by flame hydrolysis is conventionally known. However, the growing mechanism of the product particles that is, in general, seriously influenced by the reaction temperature, the gas flow velocity, the cooling rate, or the like, has not been sufficiently clarified.

DISCLOSURE OF THE INVENTION

[0011] In light of the applications of the previously mentioned ultrafine metal oxides, objects of the present invention are to provide a convenient production process for a surface-modified ultrafine mixed-crystal oxide, and to provide the ultrafine mixed-crystal oxide obtained by the process.

[0012] The inventors of the present invention have conducted an intensive investigation in view of the prior art. As a result, the above-mentioned problems were solved by producing an ultrafine mixed-crystal oxide comprising primary particles in a mixed crystal state and having a BET specific surface area of 10 to 200 m²/g in such a manner that a mixed gas (hereinafter referred to as "a mixed halogenated metal gas") comprising at least two compounds selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon (In the present invention, silicon element is grouped together with a metal element), and aluminum and an oxidizing gas are independently preheated to 500°C or more prior to a reaction.

[0013] Namely, the present invention provides:

(1) a process for producing an ultrafine mixed-crystal oxide characterized by producing an ultrafine mixed-crystal oxide comprising primary particles in a mixed crystal state and having a BET specific surface area of 10 to 200 m²/g, comprising the step of subjecting a halogenated metal to high temperature oxidation with an oxidizing gas to produce a metal oxide by a vapor phase production method, wherein the halogenated metal is in the form of a mixed gas (a mixed halogenated metal gas) comprising at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum, and the mixed halogenated metal gas and the oxidizing gas are independently preheated to 500°C or more prior to a reaction;

(2) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1), wherein the mixed halogenated metal gas is prepared by independently vaporizing at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum, and mixing the compounds in a gaseous state;

(3) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1) or (2), wherein the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum consists of TiCl₂, TiCl₃, TiCl₄, TiBr₃, TiBr₄, SiCl₄, Si₂Cl₆, Si₃Cl₈, Si₃Cl₁₀, Si₅Cl₁₂, Si₁₀Cl₁₂, SiBr₄, Si₂Br₆, Si₃Br₈, Si₄Br₁₀, SiI₄, Si₂I₆, SiCl₂I₂, SiClI₃, SiBr₃I, SiHI₃, SiCl₃I, SiH₃Br, SiH₂Br₂, SiHBr₃, SiCl₃Br, SiCl₂Br₂, SiClBr₃, AlCl₃, AlBr₃, and AlI₃;

(4) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1), wherein the mixed halogenated metal gas and the oxidizing gas which are independently preheated to 500°C or more are separately supplied to a reaction tube at a flow velocity of 10 m/sec or more to carry out the reaction;

(5) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1), wherein the reaction is carried out with the mixed halogenated metal gas and the oxidizing gas by retaining in the reaction tube for 1 second or less under the condition that the temperature in the reaction tube exceeds 600°C;

(6) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1), wherein the gases in the reaction tube have an average flow velocity of 5 m/sec or more;

(7) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1), wherein the preheated mixed halogenated metal gas and the preheated oxidizing gas cause turbulent flow when supplied to the reaction tube;

(8) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1) or (4), wherein the mixed halogenated metal gas and the oxidizing gas are supplied to the reaction tube through a coaxial parallel flow nozzle which has an internal tube with an inner diameter of 50 mm or less;

(9) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1), wherein a concentration of a halogenated metal in the aforementioned mixed halogenated metal gas is in a range of 10 to 100% by volume;

(10) the production process of the ultrafine mixed-crystal oxide according to the aforementioned item (1) or (4), wherein the aforementioned mixed halogenated metal gas and oxidizing gas are preheated to 800°C or more;

(11) an ultrafine mixed-crystal oxide produced by the process according to any one of the aforementioned items (1) to (10);

- (12) the ultrafine mixed-crystal oxide as described in the aforementioned item (11), wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having a titanium-oxygen-silicon bond;
- 5 (13) the ultrafine mixed-crystal oxide as described in the aforementioned item (11), wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having a titanium-oxygen-aluminum bond;
- (14) the ultrafine mixed-crystal oxide as described in the aforementioned item (12) or (13), wherein the oxide has a BET specific surface area decreasing ratio of 10% or less after heating at 800°C for one hour;
- 10 (15) the ultrafine mixed-crystal oxide as described in the aforementioned item (12) or (13), wherein the oxide has a change in absorbance of about 5 (1/hr) or less when measured in a manner that the oxide is dispersed at a concentration of 0.067% in a solvent of a 98% glycerin in which Sunset Yellow is dissolved at a concentration of 0.02%, thereby preparing a dispersion, and the dispersion is irradiated with a BLB lamp (ultraviolet light) with an intensity of 1.65 mW/cm² to obtain the change in absorbance (ΔOD) at 490 nm;
- 15 (16) the ultrafine mixed-crystal oxide as described in the aforementioned item (11), wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having an aluminum-oxygen-silicon bond;
- (17) the ultrafine mixed-crystal oxide as described in the aforementioned item (12), (13) or (16), wherein the oxide has an A/B ratio is 0.001 or less when A is the content (%) of chlorine, and B is the BET specific surface area (m²/g);
- 20 (18) an ultrafine mixed-crystal oxide composition characterized by comprising the ultrafine mixed-crystal oxides described in any one of the aforementioned items (11) to (17);
- (19) an aqueous slurry characterized by comprising the ultrafine mixed-crystal oxide described in any one of the aforementioned items (11) to (17);
- (20) an organic polymer composition characterized by comprising the ultrafine mixed-crystal oxide described in any one of the aforementioned items (11) to (17);
- 25 (21) the organic polymer composition as described in the aforementioned item (20), wherein an organic polymer in the organic polymer composition is at least one kind of organic polymer selected from the group consisting of a synthetic thermoplastic resin, a synthetic thermosetting resin, and a natural resin;
- (22) the organic polymer composition as described in the aforementioned item (20), wherein a concentration of the ultrafine mixed-crystal oxide in the organic polymer composition is in a range of 0.01 to 80 mass % of total mass of the composition;
- 30 (23) a paint comprising the organic polymer composition described in the aforementioned item (20);
- (24) a compound comprising the organic polymer composition described in the aforementioned item (20);
- (25) a master batch for a molded material selected from the group consisting of fiber, film, or molded plastic, using the organic polymer composition described in the aforementioned item (20) containing the ultrafine mixed-crystal oxide in a high concentration;
- 35 (26) a molded body obtained by molding the organic polymer composition described in the aforementioned item (20);
- (27) the molded body as described in the aforementioned item (26), wherein the molded body is a fiber, a film, and a molded plastic; and
- 40 (28) a structural body comprising a structural material and the ultrafine mixed-crystal oxide described in any one of the aforementioned items (11) to (17) on a surface of the structural material.

BRIEF DESCRIPTION OF THE DRAWING

45 [0014]

FIG. 1 is a schematic diagram of one example of a reaction tube with a coaxial parallel flow nozzle, which tube is preferably used in the present invention.

50 DETAILED DESCRIPTION OF THE INVENTION

[0015] The present invention will now be explained in detail.

55 [0016] The present invention relates to a process for producing an ultrafine mixed-crystal oxide characterized by producing an ultrafine mixed-crystal oxide comprising primary particles in a mixed crystal state and having a BET specific surface area of 10 to 200 m²/g, comprising the step of subjecting a halogenated metal to high temperature oxidation with an oxidizing gas to produce a metal oxide by a vapor phase production method, wherein the halogenated metal is in the form of a mixed halogenated metal gas comprising at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium,

silicon, and aluminum, and the mixed halogenated metal gas and the oxidizing gas are independently preheated to 500°C or more prior to a reaction.

[0017] In the above-mentioned production process of the ultrafine mixed-crystal oxide, it is preferable that the mixed halogenated metal gas comprises at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum. When the mixed halogenated metal gas is supplied to a reaction tube, it is preferable that the halogenated metals be independently vaporized into a gaseous state, followed by mixing in the gaseous state. As the oxidizing gas, oxygen, water vapor, or a mixed gas comprising oxygen and water vapor is used.

[0018] The chlorides, bromides, and iodides of titanium, silicon, and aluminum for use in the present invention are not limited. Any halogenated metal that can at least produce the corresponding halogenated metal gas when preheated to 500°C or more is usable. For example, TiCl_2 , TiCl_3 , TiCl_4 , TiBr_3 , TiBr_4 , SiCl_4 , Si_2Cl_6 , Si_3Cl_8 , $\text{Si}_3\text{Cl}_{10}$, $\text{Si}_5\text{Cl}_{12}$, $\text{Si}_{10}\text{Cl}_{12}$, SiBr_4 , Si_2Br_6 , Si_3Br_8 , $\text{Si}_4\text{Br}_{10}$, SiI_4 , Si_2I_6 , SiCl_2I_2 , SiClI_3 , SiBr_3I , SiH_3I , SiCl_3I , SiH_3Br , SiH_2Br_2 , SiHBr_3 , SiCl_3Br , SiCl_2Br_2 , SiClBr_3 , AlCl_3 , AlBr_3 , and AlI_3 can be given as examples. Of these examples, TiCl_4 , TiBr_4 , SiCl_4 , and AlCl_3 are particularly preferable.

[0019] In the present invention, the above-mentioned mixed halogenated metal gas and the oxidizing gas are required to be independently preheated to 500°C or more, preferably 800°C or more before the reaction. When the preheating temperatures of the mixed halogenated metal gas and the oxidizing gas are lower than 500°C, uniform nucleation is decreased, and the reactivity is reduced. Therefore, it is difficult to produce ultrafine particles, and the residual content of chlorine is increased after dechlorination.

[0020] In the present invention, it is desirable that the mixed halogenated metal gas and the oxidizing gas be separately supplied to a reaction tube at a flow velocity of 10 m/sec or more, more preferably 30 m/sec or more. In addition, it is preferable to carry out the reaction of these gases in such a manner that the gases are retained in the reaction tube under the condition of high temperatures of 600°C or more to have a reaction time (which will also be hereinafter referred to as "high-temperature residence time") of 1 second or less.

[0021] The inventors of the present invention have intensively studied the growing mechanism of particles in the vapor phase method. As a result, an oxide can be favorably obtained in the form of ultrafine particles by controlling both growing stages of the chemical vapor deposition (CVD) growing mechanism and the particle growing mechanism due to coalescence of particles by collision and sintering which are factors having an effect on the particle growth, to be curtailed. In other words, with respect to the former factor for growth, the growth of an oxide can be controlled when the chemical reactivity (reaction rate) is enhanced by elevating the preheating temperature. Concerning the latter factor for particle growth, the growth caused by sintering or the like can be inhibited when the high-temperature residence time is minimized by rapid cooling and diluting after completion of the CVD. Under such production conditions, an ultrafine mixed-crystal oxide with a BET specific surface area of 10 to 200 m^2/g , preferably 10 to 100 m^2/g , can be obtained.

[0022] It is preferable that the flow velocities of the mixed halogenated metal gas and the oxidizing gas be 10 m/sec or more when the gases are introduced into the reaction tube. This is because the mixing of gases can be promoted by increasing the flow velocities. When the gases have temperatures of 500°C or more on entering the reaction tube, the reaction is completed simultaneously with the mixing step, so that uniform nucleation is promoted. In addition, it is possible to curtail the CVD-governed particle growing zone.

[0023] In the present invention, it is preferable that the material gas be introduced into the reaction tube in a condition that the gases introduced there are thoroughly mixed. As long as the gases are sufficiently mixed, the fluid state of gas in the reaction tube is not particularly limited. For example, a fluid state capable of causing turbulent flow is preferable. There may exist a spiral flow.

[0024] In the present invention, once the gases are supplied to the reaction tube, the larger the flow velocities of the gases in the reaction tube the better in order to perfectly mix the gases. In particular, it is preferable that the average flow velocity be 5 m/sec or more. When the flow velocity of each gas in the reaction tube is 5 m/sec or more, the gases can be thoroughly mixed in the reaction tube.

[0025] As a nozzle for introducing the material gas into the reaction tube, nozzles that can provide a coaxial parallel flow, oblique flow, or cross flow are employed, but not limited thereto. In general, the coaxial parallel flow nozzle is preferably employed from the viewpoint of design because the structure thereof is simpler although the coaxial parallel flow nozzle is inferior to other nozzles that can provide oblique flow or cross flow in terms of mixing performance. For example, when the coaxial parallel flow nozzle is employed, a chloride-containing-gas is introduced into the internal tube, and the oxidizing gas is introduced into the external tube. In this case, it is preferable that the internal tube have a diameter of 50 mm or less, and more preferably 50 mm to 10 mm, from the viewpoint of mixing of gases.

[0026] The reaction in the reaction tube is an exothermic reaction, and the reaction temperature is higher than the sintering temperature for the resulting ultrafine titanium oxide. Although heat is lost by radiation from the reaction vessel, sintering of the resulting ultrafine particles proceeds to promote particle growth unless the reaction product is rapidly cooled after the reaction. In the present invention, it is preferable to set the high-temperature residence time

at 600°C or more in the reaction tube to 1 second or less, followed by rapid cooling.

[0027] To rapidly cool the particles after the reaction, there are the methods of introducing large quantities of cooling air or nitrogen gas or the like into the reaction mixture after the reaction, and of spraying water thereto.

[0028] FIG. 1 is a schematic diagram of a reaction tube provided with a coaxial parallel flow nozzle used for the production of the ultrafine mixed-crystal oxide according to the present invention. A mixed halogenated metal gas is preheated to a predetermined temperature in a preheater 2, and introduced into a reaction tube 3 through an internal tube of a coaxial parallel flow nozzle 1. An oxidizing gas is preheated to a predetermined temperature in a preheater 2, and introduced into the reaction tube 3 through an external tube of the coaxial parallel flow nozzle 1. The gases introduced into the reaction tube are mixed to carry out the reaction. After that, the mixed gases are rapidly cooled with a cooling gas, and sent to a bag filter 4 to collect the ultrafine mixed-crystal oxide particles.

[0029] The material gas may be made of 100% by volume of the above-mentioned mixed halogenated metal gas. Alternatively, the mixed halogenated metal gas may be diluted with an inert gas to have a concentration of 10 vol.% or more and less than 100%, preferably a concentration of 20 vol.% or more and less than 100 vol.%. When the material gas comprises the mixed halogenated metal gas at a concentration (a total concentration of halogenated metal gas) of 10 vol.% or more, uniform nucleation can be increased and the reactivity is enhanced. As the above-mentioned inert gas, any inert gas that is not reactive with the mixed halogenated metal and is not oxidized may be selected. More specifically, nitrogen and argon are preferable diluent gases.

[0030] The ultrafine mixed-crystal oxide obtained by the production process according to the present invention will now be explained.

[0031] The ultrafine mixed-crystal oxide of the present invention has a BET specific surface area of 10 to 200 m²/g. In the case where at least a compound containing titanium and a compound containing silicon are used for the mixed halogenated metal gas serving as the raw material in the production process of the present invention, there can be obtained an ultrafine mixed-crystal oxide comprising primary particles in a mixed crystal state with a titanium-oxygen-silicon bond. The above-mentioned ultrafine mixed-crystal oxide has an average primary particle diameter of 0.008 to 0.1 μm, preferably 0.015 to 0.1 μm.

[0032] The BET specific surface area decreasing ratio obtained after heating was evaluated as an indication of the resistance to sintering properties of the ultrafine mixed-crystal oxide (the measuring method is described later). As a result, the ultrafine mixed-crystal oxide comprising the above-mentioned titanium-oxygen-silicon bond has the characteristic that the BET specific surface area decreasing ratio is 10% or less after the oxide is heated at 800°C for one hour.

[0033] With respect to the ultrafine mixed-crystal oxide of the present invention, when at least a compound containing titanium and a compound containing aluminum are used for the mixed halogenated metal gas serving as the raw material, an ultrafine mixed-crystal oxide comprising primary particles in a mixed crystal state with a titanium-oxygen-aluminum bond can be obtained. In this case, the ultrafine mixed-crystal oxide comprising the above-mentioned titanium-oxygen-aluminum bond has the characteristic that the BET specific surface area decreasing ratio is 10% or less after the oxide is heated at 800°C for one hour.

[0034] Further, with respect to the ultrafine mixed-crystal oxide of the present invention, when at least a compound containing aluminum and a compound containing silicon are used for the mixed halogenated metal gas serving as the raw material, an ultrafine mixed-crystal oxide comprising primary particles in a mixed crystal state with an aluminum-oxygen-silicon bond can be obtained. In this case, the ultrafine mixed-crystal oxide comprising the above-mentioned aluminum-oxygen-silicon bond has the characteristic that the BET specific surface area decreasing ratio is 10% or less after the oxide is heated at 800°C for one hour.

[0035] As an indication of photo-activity of the ultrafine mixed-crystal oxide according to the present invention, the ultrafine mixed-crystal oxide (for example, comprising primary particles in a mixed-crystal state with the titanium-oxygen-silicon bond, titanium-oxygen-aluminum bond, or silicon-oxygen-aluminum bond) were characterized with regard to the decreasing rate of dye absorbance under ultraviolet light irradiation. As a result, the ultrafine mixed-crystal oxide of the present invention is characterized by a change in absorbance of 5 (/hr) or less when measured in such a manner that Sunset Yellow (dye) is dissolved at a concentration of 0.02% and the oxide is dispersed at a concentration of 0.067% in a solvent of a 98% glycerin, and the resultant dispersion is irradiated with a BLB lamp (ultraviolet light lamp) with an intensity of 1.65 mW/cm² to obtain the change in absorbance (ΔOD) at 490 nm.

[0036] In addition, it is surprisingly confirmed that the content of chlorine remaining in the oxide obtained after a dechlorination step is extremely low when silicon oxide coexists in the oxide, as compared with the case where the oxide comprises no silicon oxide.

[0037] According to the present invention, in the ultrafine mixed-crystal oxide in a mixed-crystal state having any of the above-mentioned bonds, it is preferable that the A/B ratio be 0.001 or less when A is the content (%) of chlorine, and B is the BET specific surface area (m²/g).

[0038] The ultrafine mixed-crystal oxide obtained by the production process of the present invention may have a core/shell structure, which is preferably made of a crystalline compounded structure comprising different metal oxides.

For instance, there are observed a TiO_2 -rich phase in the core, and a SiO_2 -rich phase in the shell in a titanium-silicon based ultrafine mixed-crystal oxide comprising the primary particle in a mixed-crystal state having a titanium-oxygen-silicon bond.

[0039] The ultrafine mixed-crystal oxide of the present invention can be used as a pigment, a dielectric raw material or an additive in cosmetics and clothing, and as an ultraviolet shielding agent and an abrasive in a variety of compositions such as silicone rubber and paper. A titanium-containing silicon or aluminum based mixed-crystal oxide can be used as a photocatalytic powder with a controlled photocatalytic effect. This is because such an oxide can reduce or magnify the photocatalytic properties peculiar to titanium oxide.

[0040] The aqueous slurry of the present invention means aqueous dispersant comprising the ultrafine mixed-crystal oxide. No particular limitation is imposed on an amount of the ultrafine mixed-crystal oxide contained in the slurry. For example, the amount is preferable to be in a range of 0.01 to 50 mass %, more preferably 1 to 40 mass %. When the amount of the ultrafine mixed-crystal oxide contained in the slurry is less than 0.01 mass %, sufficient properties of the ultrafine mixed-crystal oxide can not be obtained. On the other hand when the amount of the ultrafine mixed-crystal oxide contained in the slurry is more than 50 mass %, it results in arising problems of increasing viscosity and economical disadvantage.

[0041] To this aqueous dispersant (slurry), arbitrary amount of binder is added to produce a coating agent. A structural body containing the ultrafine mixed-crystal oxide on its surface is produced by painting the coating agent on a surface of various structural materials described later. In the present invention, no particular limitation is imposed on the binder material, both organic and inorganic binder can be preferably used. Specific examples of the organic binder include poly(vinyl alcohol), melamine resin, urethane resin, celluloid, chitin, starch sheet, polyacrylamide, and acrylamide. Examples of the inorganic binder include zirconium compound such as zirconium oxychloride, zirconium hydroxychloride, zirconium nitrate, zirconium sulfate, zirconium acetate, zirconium ammonium carbonate, zirconium propionate; silicon compound such as silane alkoxide, silicate; and metal alkoxide such as aluminum alkoxide, titanium alkoxide.

[0042] The amount of the binder added in the coating agent, for example, is preferably in a range of 0.01 to 20 mass %, more preferably 1 to 10 mass %. When the binder content is less than 0.01 mass %, sufficient adhesive property after coating treatment can not be obtained. When the binder content is more than 20 mass %, it results in arising problems of increasing viscosity and economical disadvantage.

[0043] The ultrafine mixed-crystal oxide of the present invention can be added in a organic polymer to produce a composition for use. The organic polymer to be used includes a synthetic thermoplastic resin, a synthetic thermosetting resin, and a natural resin etc.. Specific examples of the organic polymer include polyolefin such as polyethylene, polypropylene, and polystyrene; polyamide such as nylon 6, nylon 66, and aramid; polyester such as polyethylene terephthalate, and unsaturated polyester; polyvinylchloride, polyvinylidene chloride, polyethylene oxide, polyethylene glycol, silicon resin, poly(vinyl alcohol), vinyl acetal resin, polyacetate, ABS resin, epoxy resin, vinyl acetate resin, cellulose and cellulose derivatives such as rayon, urethane resin, polyurethane resin, polycarbonate resin, urea resin, fluororesin, poly(vinylidene fluoride), phenol resin, celluloid, chitin, starch sheet, acryl resin, melamine resin, alkyd resin.

[0044] The organic polymer composition containing the ultrafine mixed-crystal oxide of the present invention can be used as a paint (coating composition), a compound, and a masterbatch. A concentration of the ultrafine mixed-crystal oxide in the organic polymer composition based on a total mass of the composition is preferably 0.01 to 80 mass %, more preferably 1 to 50 mass %.

[0045] In the present invention, a molded body can be obtained by molding the above described polymer composition. The molded composition include fiber, film, and molded plastic.

[0046] Further, the organic polymer composition of the present invention having superior durability can be used as a coating composition for a structural material such as a wall material, a glass, a signboard, and a concrete for construction of the road. When the coating composition is applied to structural materials (organic material) such as paper, plastics, fabric, and wood; or to vehicles, it can be free of deterioration or defect of the coating.

BEST MODE FOR CARRYING OUT THE INVENTION

[0047] The present invention will now be explained in more detail with reference to the following examples, but the present invention is not particularly limited by these examples.

<Evaluation of resistance to sintering properties>

[0048] The BET specific surface area decreasing ratio after heating the oxide was determined as an indication of the resistance to sintering properties of the ultrafine mixed-crystal oxide according to the present invention.

[0049] 1 g of a raw material powder was placed in an aluminum crucible and heated at 800°C for one hour in a silicon furnace. After the powder was cooled to room temperature, the BET specific surface area was measured. When the BET specific surface area of the raw material powder is represented by B_1 (m^2/g) and the BET specific

surface area after heating is represented by B2 (m²/g), the BET specific surface area decreasing ratio is defined in accordance with the following formula:

BET specific surface

$$\text{area decreasing ratio} = \{1 - (B2/B1)\} \times 100 (\%)$$

[0050] The smaller the BET specific surface area decreasing ratio, the superior the resistance to the sintering properties to be evaluated.

<Evaluation of photo-activity>

[0051] To evaluate the photo-activity of the ultrafine mixed-crystal oxide according to the present invention, the dye absorbance decreasing rate by ultraviolet irradiation was employed as an indication.

[0052] In a 98% glycerin serving as a solvent, Sunset Yellow (azo dye) was dissolved at a concentration of 0.02% and the oxide was dispersed at a concentration of 0.067%. The resultant dispersion was placed in a quartz glass cell, and irradiated with a BLB lamp (ultraviolet lamp) with an intensity of 1.65 mW/cm². The absorbance at 490 nm was measured at regular intervals, and the decreasing rate, ΔOD, (unit: per hour) was obtained. As the value of ΔOD becomes smaller, the photo-activity is considered to be more restrained.

<Evaluation of mixed-crystal state>

[0053] To identify the mixed-crystal state in the present invention, X-ray photoelectron spectrometry (XPS) is employed. The details are referred to in A.Yu.Stakheev et al, J.Phys. Chem., 97(21), 5668-5672 (1993).

Example 1:

[0054] 9.4 Nm³/hour ("N" means standard conditions, and the same meaning applies correspondingly to the following) of gaseous titanium tetrachloride with a concentration of 100 vol.%, and 2.4 Nm³/hour of gaseous silicon tetrachloride with a concentration of 100 vol.% were mixed to prepare a material gas, and preheated to 1000°C. A mixed gas of 8 Nm³/hour of oxygen and 20 Nm³/hour of water vapor was preheated to 1000°C. Both the material gas and the mixed gas were introduced into a reaction tube at respective flow velocities of 49 m/sec and 60 m/sec, using a coaxial parallel flow nozzle. For the reaction, a reaction tube such as shown in FIG. 1 was employed, which reaction tube was provided with a coaxial parallel flow nozzle having an internal tube with a diameter of 20 mm. The mixed halogenated metal containing gas was introduced through the internal tube.

[0055] The inner diameter of the reaction tube was 100 mm, and the counted value of the flow velocity in the tube at the reaction temperature of 1,300°C was 10 m/sec. Cooling air was introduced into the reaction tube after the reaction so that the high-temperature residence time in the reaction tube was 0.3 sec or less. Thereafter, the produced ultrafine particles were collected using a Teflon bag filter. The ultrafine particles were then heated at 500°C for one hour under atmospheric conditions using an oven, thereby performing a dechlorination process.

[0056] With respect to the obtained ultrafine mixed-crystal oxide, the BET specific surface area was 88 m²/g, the average true specific gravity was 3.7 g/cc, the average primary particle diameter was 0.018 μm, and the residual content of chlorine was 0.01%. The titanium-oxygen-silicon bond was apparently confirmed by the XPS.

[0057] In addition, the photo-activity (hereinafter referred to as "ΔOD") was 0.1/hr, the BET specific surface area decreasing ratio after completion of the heating at 800°C for one hour (hereinafter referred to as "ΔB") was 2%, and the ratio of the chlorine content to the BET specific surface area (hereinafter referred to as "A/B") was 0.0001.

Example 2:

[0058] 8.3 Nm³/hour of gaseous titanium tetrachloride, 2.4 Nm³/hour of gaseous aluminum trichloride, and 6 Nm³/hour of nitrogen were mixed to prepare a material gas, and preheated to 900°C. A mixed gas of 8 Nm³/hour of oxygen and 20 Nm³/hour of water vapor was preheated to 1000°C. Both the material gas and the mixed gas were introduced into a reaction tube at respective flow velocities of 63 m/sec and 60 m/sec, using a coaxial parallel flow nozzle. For the reaction, a reaction tube such as shown in FIG. 1 was employed, which reaction tube was provided with a coaxial parallel flow nozzle having an internal tube with a diameter of 20 mm. The gas containing mixed halogenated metal was introduced through the internal tube.

[0059] The inner diameter of the reaction tube was 100 mm, and the counted value of the flow velocity in the tube

at the reaction temperature of 1,200°C was 10 m/sec. Cooling air was introduced into the reaction tube after the reaction so that the high-temperature residence time in the reaction tube was 0.3 sec or less. Thereafter, the produced ultrafine particles were collected using a Teflon bag filter. The ultrafine particles were then heated at 500°C for one hour under atmospheric conditions using an oven, thereby performing a dechlorination process.

[0060] With respect to the obtained ultrafine mixed-crystal oxide, the BET specific surface area was 48 m²/g, the average true specific gravity was 3.9 g/cc, the average primary particle diameter was 0.032 μm, and the residual content of chlorine was 0.1%. The titanium-oxygen-aluminum bond was apparently confirmed by the XPS.

[0061] In addition, the value of ΔOD was 1.2/hr, the value of ΔB was 5%, and the A/B ratio was 0.002.

Example 3:

[0062] 1.2 Nm³/hour of gaseous silicon tetrachloride, 8.3 Nm³/hour of gaseous aluminum trichloride, and 10 Nm³/hour of nitrogen were mixed to prepare a material gas, and preheated to 1,000°C. A mixed gas of 8 Nm³/hour of oxygen and 20 Nm³/hour of water vapor was preheated to 1000°C. Both the material gas and the mixed gas were introduced into a reaction tube at respective flow velocities of 80 m/sec and 60 m/sec, using a coaxial parallel flow nozzle. For the reaction, a reaction tube such as shown in FIG. 1 was employed, which reaction tube was provided with a coaxial parallel flow nozzle having an internal tube with a diameter of 20 mm. The gas containing mixed halogenated metal was introduced through the internal tube.

[0063] The inner diameter of the reaction tube was 100 mm, and the counted value of the flow velocity in the tube at the reaction temperature of 1,200°C was 11 m/sec. Cooling air was introduced into the reaction tube after the reaction so that the high-temperature residence time in the reaction tube was 0.3 sec or less. Thereafter, the produced ultrafine particles were collected using a Teflon bag filter. The ultrafine particles were then heated at 500°C for one hour under atmospheric conditions using an oven, thereby performing a dechlorination process.

[0064] With respect to the obtained ultrafine mixed-crystal oxide, the BET specific surface area was 120 m²/g, the average true specific gravity was 3.5 g/cc, the average primary particle diameter was 0.014 μm, and the residual content of chlorine was 0.004%. The silicon-oxygen-aluminum bond was apparently confirmed by the XPS.

[0065] In addition, the value of ΔB was 2%, and the A/B ratio was 0.00003.

Comparative Example 1:

[0066] 10.7 Nm³/hour of gaseous titanium tetrachloride and 12 Nm³/hour of nitrogen were mixed to prepare a material gas, and preheated to 900°C. A mixed gas of 8 Nm³/hour of oxygen and 20 Nm³/hour of water vapor was preheated to 1000°C. Both the material gas and the mixed gas were introduced into a reaction tube at respective flow velocities of 86 m/sec and 60 m/sec, using a coaxial parallel flow nozzle. For the reaction, a reaction tube such as shown in FIG. 1 was employed, which reaction tube was provided with a coaxial parallel flow nozzle having an internal tube with a diameter of 20 mm. The gas containing the halogenated metal was introduced through the internal tube.

[0067] The inner diameter of the reaction tube was 100 mm, and the counted value of the flow velocity in the tube at the reaction temperature of 1,200°C was 12 m/sec. Cooling air was introduced into the reaction tube after the reaction so that the high-temperature residence time in the reaction tube was 0.3 sec or less. Thereafter, the produced ultrafine particles were collected using a Teflon bag filter. The ultrafine particles were then heated at 500°C for one hour under atmospheric conditions using an oven, thereby performing a dechlorination process.

[0068] With respect to the obtained ultrafine oxide, the BET specific surface area was 51 m²/g, the average true specific gravity was 4.0 g/cc, the average primary particle diameter was 0.029 μm, and the residual content of chlorine was 0.4%.

[0069] In addition, the value of ΔOD was 21/hr, the value of ΔB was 62%, and the A/B ratio was 0.007. This product is found to have higher photo-activity, and to be more easily sintered when compared with the products produced in Examples 1 and 2. In addition, there remains much amount of chlorine.

Comparative Example 2:

[0070] 8.3 Nm³/hour of gaseous aluminum trichloride and 20 Nm³/hour of nitrogen were mixed to prepare a material gas, and preheated to 1,000°C. A mixed gas of 8 Nm³/hour of oxygen and 20 Nm³/hour of water vapor was preheated to 1,000°C. Both the material gas and the mixed gas were introduced into a reaction tube at respective flow velocities of 107 m/sec and 60 m/sec, using a coaxial parallel flow nozzle. For the reaction, a reaction tube such as shown in FIG. 1 was employed, which reaction tube was provided with a coaxial parallel flow nozzle having an internal tube with a diameter of 20 mm. The gas containing the halogenated metal was introduced through the internal tube.

[0071] The inner diameter of the reaction tube was 100 mm, and the counted value of the flow velocity in the tube at the reaction temperature of 1,200°C was 12 m/sec. Cooling air was introduced into the reaction tube after the reaction

so that the high-temperature residence time in the reaction tube was 0.3 sec or less. Thereafter, the produced ultrafine particles were collected using a Teflon bag filter. The ultrafine particles were then heated at 500°C for one hour under atmospheric conditions using an oven, thereby performing a dechlorination process.

5 [0072] With respect to the obtained ultrafine oxide, the BET specific surface area was 115 m²/g, the average true specific gravity was 3.7 g/cc, the average primary particle diameter was 0.014 μm, and the residual content of chlorine was 0.5%. In addition, the value of ΔB was 7%, and the A/B ratio was 0.004.

[0073] This product is found to be more easily sintered and there remains more amount of chlorine when compared with the product produced in Example 3.

10 Example 4:

[0074] Water is added to the ultrafine mixed-crystal oxide having a titanium-oxygen-silicon bond obtained in example 1, to produce a slurry containing 0.5 mass % of the oxide on the solid powder basis. To the slurry, an aqueous dispersed urethane resin (VONDIC1040NS, produced by DAINIPPON INK AND CHEMICALS, INCORPORATED.) is added to
15 produce a coating agent containing urethane resin by 70 mass % on the solid powder basis and photo-functional powder.

[0075] The obtained coating agent is painted on one side of polyethylene terephthalate(PET) film (100 μm Lumilar T, produced by Toray Industries, Inc) by an applicator(25 μm). And the resulting film is dried at 80°C for two hours to produce a polyethylene terephthalate film including the ultrafine mixed-crystal oxide.

20 [0076] A percent transmission of the obtained polyethylene terephthalate film is measured by spectrometer(UV-2400PC, produced by Shimadzu Co., Ltd) to be 1% (360 nm) and 89 % (550 nm).

[0077] A light resistance test is conducted to the above described polyethylene terephthalate film by applying a light of 76 mW/cm² using fademeter (SUNSET CPS+, produced by Heraeus), and coloring of the film after 100 hours is investigated. No coloring is observed.

25 Example 5:

[0078] 20 mass parts of the ultrafine mixed-crystal oxide having a titanium-oxygen-silicon bond obtained in example 1, 2 mass parts of zinc stearate (zinc stearate S, produced by NOF CORPORATION), 78 mass parts of low density polyethylene (LDPE) (JAPAN POLYOLEFINS CO., Ltd.) is melt-kneaded at 160°C (residence time is about 3 minutes) using biaxial extruder (PCM type 30, produced by Ikegai tekkou Co., Ltd.), and foamed to pellet, to produce 20 kg of a cylinder shaped compound of low density polyethylene having a diameter of 2 ~ 3 mm, a length of 3 ~ 5 mm, and a weight of 0.01 ~ 0.02 g, containing 20 % of the ultrafine mixed-crystal oxide.

35 [0079] 1 kg of the obtained compound of low density polyethylene containing the ultrafine mixed-crystal oxide and 39 kg of low density polyethylene (LDPE) (JAPAN POLYOLEFINS CO., Ltd.) are mixed using V-type blender(RKI-40, produced by IKEMOTO SCIENTIFIC TECHNOLOGY CO., LTD) for 10 minutes to produce a mixed pellet.

[0080] The obtained mixed pellet is molded using inflation film molding machine equipped with 40 mm φ of extruder (YEI-S40-40L, produced by YOSHIITEKKOU CO., LTD) to produce 40 μm of inflation film. Transmission and light resistance tests are conducted to the obtained film in the same procedure as in example 4. The results obtained are
40 shown in Table 1 below.

Comparative Example 3:

45 [0081] A purchased ultrafine titanium dioxide (ST-01, produced by ISHIHARA INDUSTRIES CO., LTD.) is treated and tested in the same procedure as in example 4. The results obtained are shown in Table 1 below.

Comparative Example 4:

50 [0082] A purchased ultrafine titanium dioxide (ST-01, produced by ISHIHARA INDUSTRIES CO., LTD.) is treated and tested in the same procedure as in example 4. The results obtained are shown in Table 1 below.

Table 1

	Additives	Application	Light resistance test	% trans- mission (350 nm)	% trans- mission (550 nm)
Example 4	Ultrafine mixed-crystal oxide containing titanium- oxygen-silicon bond	Painting on PET film	No coloring	1%	89%
Example 5	Ultrafine mixed-crystal oxide containing titanium- oxygen-silicon bond	LDPE inflation film	No coloring	0%	78%
Comparative Example 3	Ultrafine titanium dioxide	Painting on PET film	Coloring	3%	95%
Comparative Example 4	Ultrafine titanium dioxide	LDPE inflation film	Coloring	10%	60%

INDUSTRIAL APPLICABILITY

[0083] As previously explained in detail, according to the present invention, there can be provided an ultrafine mixed-crystal oxide comprising the primary particles in a mixed-crystal state, the oxide being in the form of ultrafine particles with excellent dispersion properties, and having a BET specific surface area of 10 to 200 m²/g. This is because the gas containing a mixture of halogenated metals and the oxidizing gas are independently preheated to 500°C or more prior to the reaction in the vapor phase method for producing an ultrafine mixed-crystal oxide by subjecting the mixture of halogenated metals to high temperature oxidation using the oxidizing gas.

Further, for example, the ultrafine mixed-crystal oxide of the present invention can moderate or control the photoactivity and the sintering properties thereof. The residual amount of chlorine can be drastically decreased. The step of disintegrating of the particles becomes unnecessary, or can be performed using extremely simple facilities if the step is necessary. The ultrafine mixed-crystal oxide can be produced very conveniently. The process for producing an ultrafine mixed-crystal oxide of the present invention is useful for various industrial applications.

Claims

1. A process for producing an ultrafine mixed-crystal oxide characterized by producing an ultrafine mixed crystal oxide comprising primary particles in a mixed crystal state and having a BET specific surface area of 10 to 200 m²/g, comprising the step of subjecting a halogenated metal to high temperature oxidation with an oxidizing gas to produce a metal oxide by a vapor phase production method, wherein the halogenated metal is in the form of a mixed gas (a mixed halogenated metal gas) comprising at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum, and the mixed halogenated metal gas and the oxidizing gas are independently preheated to 500°C or more prior to a reaction.
2. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the mixed halogenated metal gas is prepared by independently vaporizing at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum, and mixing the compounds in a gaseous state.
3. The production process of the ultrafine mixed-crystal oxide according to claim 1 or 2, wherein the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum consists of TiCl₂, TiCl₃, TiCl₄, TiBr₃, TiBr₄, SiCl₄, Si₂Cl₆, Si₃Cl₈, Si₃Cl₁₀, Si₅Cl₁₂, Si₁₀Cl₁₂, SiBr₄, Si₂Br₆, Si₃Br₈, Si₄Br₁₀, SiI₄, Si₂I₆, SiCl₂I₂, SiClI₃, SiBr₃I, SiHI₃, SiCl₃I, SiH₃Br, SiH₂Br₂, SiHBr₃, SiCl₃Br, SiCl₂Br₂, SiClBr₃, AlCl₃, AlBr₃, and AlI₃.
4. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the mixed halogenated metal gas and the oxidizing gas which are independently preheated to 500°C or more are separately supplied to a reaction tube at a flow velocity of 10 m/sec or more to carry out a reaction.
5. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the reaction is carried out with the mixed halogenated metal gas and the oxidizing gas by retaining in the reaction tube for 1 second or less under the condition that the temperature in the reaction tube exceeds 600°C.
6. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the gases in the reaction tube have an average flow velocity of 5 m/sec or more.
7. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the preheated mixed halogenated metal gas and the preheated oxidizing gas cause turbulent flow when supplied to the reaction tube.
8. The production process of the ultrafine mixed-crystal oxide according to claim 1 or 4, wherein the mixed halogenated metal gas and the oxidizing gas are supplied to the reaction tube through a coaxial parallel flow nozzle which has an internal tube with an inner diameter of 50 mm or less.
9. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein a concentration of a halogenated metal in the mixed halogenated metal gas is in a range of 10 to 100% by volume.
10. The production process of the ultrafine mixed-crystal oxide according to claim 1 or 4, wherein the mixed halogen-

ated metal gas and the oxidizing gas are preheated to 800°C or more.

11. An ultrafine mixed-crystal oxide produced by the process according to any one of claims 1 to 10.

12. The ultrafine mixed-crystal oxide as claimed in claim 11, wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having a titanium-oxygen-silicon bond.

13. The ultrafine mixed-crystal oxide as claimed in claim 11, wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having a titanium-oxygen-aluminum bond.

14. The ultrafine mixed-crystal oxide as claimed in claim 12 or 13, wherein the oxide has a BET specific surface area decreasing ratio of 10% or less after heated at 800°C for one hour.

15. The ultrafine mixed-crystal oxide as claimed in claim 12 or 13, wherein the oxide has a change in absorbance of 5 (hr) or less when measured in a manner that the oxide is dispersed at a concentration of 0.067% in a solvent of a 98% glycerin in which Sunset Yellow is dissolved at a concentration of 0.02%, thereby preparing a dispersion, and the dispersion is irradiated with a BLB lamp (ultraviolet light) with an intensity of 1.65 mW/cm² to obtain the change in absorbance (ΔOD) at 490 nm.

16. The ultrafine mixed-crystal oxide as claimed in claim 11, wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having an aluminum-oxygen-silicon bond.

17. The ultrafine mixed-crystal oxide as claimed in claim 12, 13 or 16, wherein the oxide has an A/B ratio of 0.001 or less when A is the content (%) of chlorine, and B is the BET specific surface area (m²/g).

18. An ultrafine mixed-crystal oxide composition **characterized by** comprising the ultrafine mixed-crystal oxide described in any one of claims 11 to 17.

19. An aqueous slurry **characterized by** comprising the ultrafine mixed-crystal oxide described in any one of claims 11 to 17.

20. An organic polymer composition **characterized by** comprising the ultrafine mixed-crystal oxide described in any one of claims 11 to 17.

21. The organic polymer composition as claimed in claim 20, wherein an organic polymer in the organic polymer composition is at least one kind of organic polymer selected from the group consisting of a synthetic thermoplastic resin, a synthetic thermosetting resin, and a natural resin.

22. The organic polymer composition as claimed in claim 20, wherein a concentration of the ultrafine mixed-crystal oxide in the organic polymer composition is in a range of 0.01 to 80 mass % of total mass of the composition.

23. A paint comprising the organic polymer composition described in claim 20.

24. A compound comprising the organic polymer composition described in claim 20.

25. A master batch for a molded body selected from the group consisting of fiber, film, or molded plastic, comprising the organic polymer composition described in claim 20 containing the ultrafine mixed-crystal oxide in a high concentration.

26. A molded body obtained by molding the organic polymer composition described in claim 20.

27. The molded body as claimed in claim 26, wherein the molded body is a fiber, a film, and a molded plastic.

28. A structural body comprising a structural material and the ultrafine mixed-crystal oxide described in any one of claims 11 to 17 on a surface of the structural material.

Amended claims under Art. 19.1 PCT

- 5 1. (AMENDED) A process for producing an ultrafine mixed-crystal oxide characterized by producing an ultrafine mixed crystal oxide comprising primary particles in a mixed crystal state and having a BET specific surface area of 10 to 200 m²/g, comprising the step of subjecting a halogenated metal to high temperature oxidation with an oxidizing gas to produce a metal oxide by a vapor phase production method, wherein the halogenated metal is in the form of a mixed gas (a mixed halogenated metal gas) comprising at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum, and the mixed halogenated metal gas and the oxidizing gas are supplied into a reaction tube at a flow velocity of 10 m/sec or more to react after each is independently preheated to 500°C or more.
- 10 2. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the mixed halogenated metal gas is prepared by independently vaporizing at least two compounds having a metal element different from each other which are selected from the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum, and mixing the compounds in a gaseous state.
- 15 3. The production process of the ultrafine mixed-crystal oxide according to claim 1 or 2, wherein the group consisting of chlorides, bromides, and iodides of titanium, silicon, and aluminum consists of TiCl₂, TiCl₃, TiCl₄, TiBr₃, TiBr₄, SiCl₄, Si₂Cl₆, Si₃Cl₈, Si₃Cl₁₀, Si₅Cl₁₂, Si₁₀Cl₁₂, SiBr₄, Si₂Br₆, Si₃Br₈, Si₄Br₁₀, SiI₄, Si₂I₆, SiCl₂I₂, SiClI₃, SiBr₃I, SiHI₃, SiCl₃I, SiH₃Br, SiH₂Br₂, SiHBr₃, SiCl₃Br, SiCl₂Br₂, SiClBr₃, AlCl₃, AlBr₃, and AlI₃.
- 20 4. (CANCELLED)
- 25 5. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the reaction is carried out with the mixed halogenated metal gas and the oxidizing gas by retaining in the reaction tube for 1 second or less under the condition that the temperature in the reaction tube exceeds 600°C.
- 30 6. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the gases in the reaction tube have an average flow velocity of 5 m/sec or more.
- 35 7. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the preheated mixed halogenated metal gas and the preheated oxidizing gas cause turbulent flow when supplied to the reaction tube.
8. (AMENDED) The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the mixed halogenated metal gas and the oxidizing gas are supplied to the reaction tube through a coaxial parallel flow nozzle which has an internal tube with an inner diameter of 50 mm or less.
- 40 9. The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein a concentration of a halogenated metal in the mixed halogenated metal gas is in a range of 10 to 100% by volume.
10. (AMENDED) The production process of the ultrafine mixed-crystal oxide according to claim 1, wherein the mixed halogenated metal gas and the oxidizing gas are preheated to 800°C or more.
- 45 11. An ultrafine mixed-crystal oxide produced by the process according to any one of claims 1 to 10.
12. The ultrafine mixed-crystal oxide as claimed in claim 11, wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having a titanium-oxygen-silicon bond.
- 50 13. The ultrafine mixed-crystal oxide as claimed in claim 11, wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having a titanium-oxygen-aluminum bond.
14. The ultrafine mixed-crystal oxide as claimed in claim 12 or 13, wherein the oxide has a BET specific surface area decreasing ratio of 10% or less after heated at 800°C for one hour.
- 55 15. The ultrafine mixed-crystal oxide as claimed in claim 12 or 13, wherein the oxide has a change in absorbance of 5 (hr) or less when measured in a manner that the oxide is dispersed at a concentration of 0.067% in a solvent of a 98% glycerin in which Sunset Yellow is dissolved at a concentration of 0.02%, thereby preparing a dispersion,

and the dispersion is irradiated with a BLB lamp (ultraviolet light) with an intensity of 1.65 mW/cm² to obtain the change in absorbance (ΔOD) at 490 nm.

16. The ultrafine mixed-crystal oxide as claimed in claim 11, wherein the oxide has a BET specific surface area of 10 to 200 m²/g, and comprises primary particles with a mixed crystal having an aluminum-oxygen-silicon bond.

17. The ultrafine mixed-crystal oxide as claimed in claim 12, 13 or 16, wherein the oxide has an A/B ratio of 0.001 or less when A is the content (%) of chlorine, and B is the BET specific surface area (m²/g).

18. An ultrafine mixed-crystal oxide composition **characterized by** comprising the ultrafine mixed-crystal oxide described in any one of claims 11 to 17.

19. An aqueous slurry **characterized by** comprising the ultrafine mixed-crystal oxide described in any one of claims 11 to 17.

20. An organic polymer composition **characterized by** comprising the ultrafine mixed-crystal oxide described in any one of claims 11 to 17.

21. The organic polymer composition as claimed in claim 20, wherein an organic polymer in the organic polymer composition is at least one kind of organic polymer selected from the group consisting of a synthetic thermoplastic resin, a synthetic thermosetting resin, and a natural resin.

22. The organic polymer composition as claimed in claim 20, wherein a concentration of the ultrafine mixed-crystal oxide in the organic polymer composition is in a range of 0.01 to 80 mass % of total mass of the composition.

23. A paint comprising the organic polymer composition described in claim 20.

24. A compound comprising the organic polymer composition described in claim 20.

25. A master batch for a molded body selected from the group consisting of fiber, film, or molded plastic, comprising the organic polymer composition described in claim 20 containing the ultrafine mixed-crystal oxide in a high concentration.

26. A molded body obtained by molding the organic polymer composition described in claim 20.

27. The molded body as claimed in claim 26, wherein the molded body is a fiber, a film, and a molded plastic.

28. A structural body comprising a structural material and the ultrafine mixed-crystal oxide described in any one of claims 11 to 17 on a surface of the structural material.

29. (ADDED) A process for producing an ultrafine mixed-crystal oxide **characterized by** producing an ultrafine mixed crystal oxide comprising primary particles in a mixed crystal state and having a BET specific surface area of 10 to 200 m²/g, comprising the step of subjecting a halogenated metal to high temperature oxidation with an oxidizing gas to produce a metal oxide by a vapor phase production method, wherein the halogenated metal is in the form of a mixed gas (a mixed halogenated metal gas) comprising one or more compounds selected from the group consisting of chlorides, bromides and iodides of silicon and one or more compounds selected from the group consisting of chlorides, bromides and iodides of titanium and aluminum, and the mixed halogenated metal gas and the oxidizing gas are independently preheated to 500°C or more prior to reaction.

30. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29, wherein the mixed halogenated metal gas is prepared by independently vaporizing one or more compounds selected from the group consisting of chlorides, bromides and iodides of silicon and one or more compounds selected from the group consisting of chlorides, bromides and iodides of titanium and aluminum, and mixing the compounds in a gaseous state.

31. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29 or 30, wherein the group consisting of chlorides, bromides and iodides of titanium, silicon, and aluminum consists of TiCl₂, TiCl₃, TiCl₄, TiBr₃, TiBr₄, SiCl₄, Si₂Cl₆, Si₃Cl₈, Si₃Cl₁₀, Si₅Cl₁₂, Si₁₀Cl₁₂, SiBr₄, Si₂Br₆, Si₃Br₈, Si₄Br₁₀, SiI₄, Si₂I₆, SiCl₂I₂,

SiCl_3I , SiBr_3I , SiH_3I , SiCl_3I , SiH_3Br , SiH_2Br_2 , SiHBr_3 , SiCl_3Br , SiCl_2Br_2 , SiClBr_3 , AlCl_3 , AlBr_3 , and AlI_3 .

5 32. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29, wherein the reaction is carried out with the mixed halogenated metal gas and the oxidizing gas by retaining in the reaction tube for 1 second or less under the condition that the temperature in the reaction tube exceeds 600°C.

33. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29, wherein the gases in the reaction tube have an average flow velocity of 5 m/sec or more.

10 34. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29, wherein the preheated mixed halogenated metal gas and the preheated oxidizing gas cause turbulent flow when supplied to the reaction tube.

15 35. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29, wherein the mixed halogenated metal gas and the oxidizing gas are supplied to the reaction tube through a coaxial parallel flow nozzle which has an internal tube with an inner diameter of 50 mm or less.

20 36. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29, wherein a concentration of a halogenated metal in the mixed halogenated metal gas is in a range of 10 to 100% by volume.

37. (ADDED) The production process of the ultrafine mixed-crystal oxide as claimed in claim 29, wherein the mixed halogenated metal gas and the oxidizing gas are preheated to 800°C or more.

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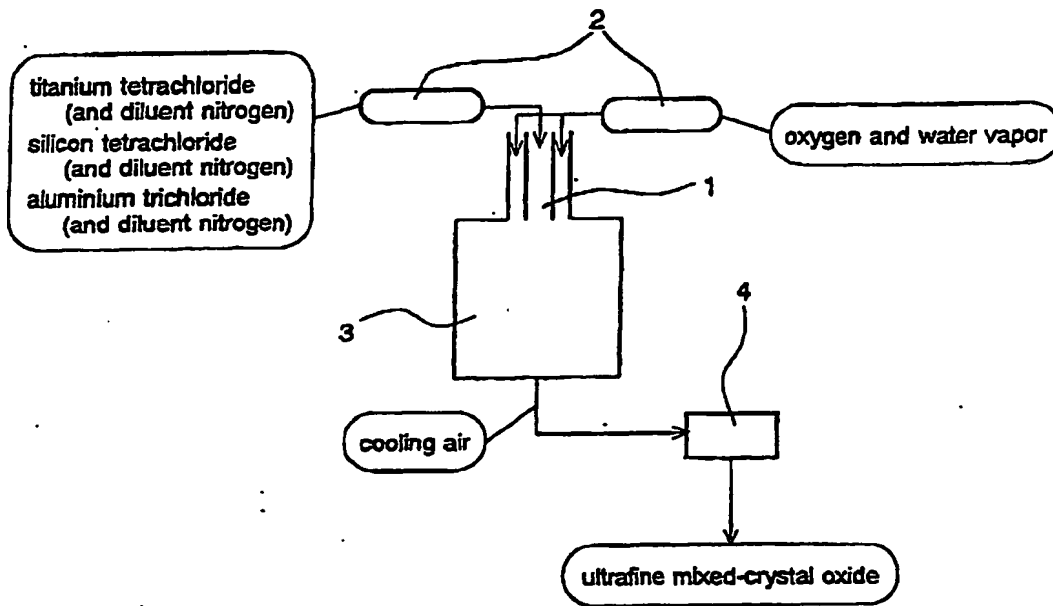
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FIG. 1



INTERNATIONAL SEARCH REPORT

International application No.

PCT/JP01/00743

A. CLASSIFICATION OF SUBJECT MATTER
Int.Cl⁷ C01G 23/07

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

Int.Cl⁷ C01G 23/00, C09D7/12, C09D201/00, C01B33/00

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Jitsuyo Shinan Koho	1926-1996	Toroku Jitsuyo Shinan Koho	1994-2001
Kokai Jitsuyo Shinan Koho	1971-2001	Jitsuyo Shinan Toroku Koho	1996-2001

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	WO, 96/00699, A (E.I. DU PONT DE NEMOURS AND COMPANY), 11 January, 1996 (11.01.96), page 2, lines 28 to 32; page 3, line 9 to page 4, line 28; working example & JP, 9-511985, A (E.I. Du Pont de Nemours and Company), 02 December, 1997 (02.12.97), Claims; page 4, lines 23 to 28; page 5, line 10 to page 7, line 5; working example & US, 5562764, A	1-28
X	US, 5599519, A (Tioxide Group Services Limited), 04 February, 1997 (04.02.97), Claims; Column 3, lines 10 to 39; working example & JP, 6-171941, A (Tioxide Group Services Limited), 21 June, 1994 (21.06.94), Claims; Par. Nos. [0014] to [0017]; working example & EP, 583063, A	1-28
A	JP, 10-509687, A (E.I. Du Pont de Nemours and Company), 22 September, 1998 (22.09.98), Claims; working example	1-28

☒ Further documents are listed in the continuation of Box C.
 ☐ See patent family annex.

* Special categories of cited documents:	"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
"A" document defining the general state of the art which is not considered to be of particular relevance	"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
"E" earlier document but published on or after the international filing date	"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	"&" document member of the same patent family
"O" document referring to an oral disclosure, use, exhibition or other means	
"P" document published prior to the international filing date but later than the priority date claimed	

Date of the actual completion of the international search
24 April, 2001 (24.04.01)Date of mailing of the international search report
01 May, 2001 (01.05.01)Name and mailing address of the ISA/
Japanese Patent Office

Authorized officer

Facsimile No.

Telephone No.

INTERNATIONAL SEARCH REPORT

International application No.

PCT/JP01/00743

C (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	& WO, 9617804, A & US, 5538708, A & EP, 796225, A	
	JP, 55-080721, A (E.I. Du Pont de Nemours and Company), 18 June, 1980 (18.06.80), Claims; page 2, lower left column, lines 4 to 19; working example & GB, 2037266, A & FR, 2443423, A	1-28
A	JP, 11-509888, A (Merck Patent GmbH), 31 August, 1999 (31.08.99), Claims; working example & DE, 19618564, A & WO, 97/43346, A & EP, 837911, A	1-28

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